

ABSTRACT OF THE INVENTION

A method of patterning a functional material onto a substrate comprises the steps of (a) applying a layer of functional material to at least one major surface of the substrate; (b) applying a layer of protective material, soluble in a solvent in which the functional material is insoluble, over the layer of functional material; (c) removing areas of the layers of protective and functional materials in well-defined regions on the substrate; and (d) removing the remaining exposed protective material from the substrate by dissolution in the solvent.